

L Number	Hits	Search Text	DB	Time stamp
1	530	((multi\$1layer\$3 multiple\$1layer\$3 double\$1layer\$3 two\$1layer\$3 triple\$1layer\$2)near7(source and drain))	USPAT; US-PGPUB	2003/12/30 20:55
2	296	((multi\$1layer\$3 multiple\$1layer\$3 double\$1layer\$3 two\$1layer\$3 triple\$1layer\$2)near7(source and drain))) and(thin adj film adj transistor\$2 tft lcd soi display\$2 silicon adj insulator\$2)	USPAT; US-PGPUB	2003/12/30 20:55
3	238	(( contact via through) adj3( hole\$2)) and (( ((multi\$1layer\$3 multiple\$1layer\$3 double\$1layer\$3 two\$1layer\$3 triple\$1layer\$2)near7(source and drain))) and(thin adj film adj transistor\$2 tft lcd soi display\$2 silicon adj insulator\$2))	USPAT; US-PGPUB	2003/12/30 21:02
4	172	((molybdenum MO chrom\$4 cr tantalum ta tungsten titanium)near21(aluminum))and ((( contact via through) adj3( hole\$2)) and (( ((multi\$1layer\$3 multiple\$1layer\$3 double\$1layer\$3 two\$1layer\$3 triple\$1layer\$2)near7(source and drain))) and(thin adj film adj transistor\$2 tft lcd soi display\$2 silicon adj insulator\$2)))	USPAT; US-PGPUB	2003/12/30 21:00
5	187	((multi\$1layer\$3 multiple\$1layer\$3 double\$1layer\$3 two\$1layer\$3 triple\$1layer\$2)near7(source and drain))	EPO; JPO; DERWENT	2003/12/30 20:55
6	51	((multi\$1layer\$3 multiple\$1layer\$3 double\$1layer\$3 two\$1layer\$3 triple\$1layer\$2)near7(source and drain))) and(thin adj film adj transistor\$2 tft lcd soi display\$2 silicon adj insulator\$2)	EPO; JPO; DERWENT	2003/12/30 20:56
7	7	(( contact via through) adj3( hole\$2)) and (( ((multi\$1layer\$3 multiple\$1layer\$3 double\$1layer\$3 two\$1layer\$3 triple\$1layer\$2)near7(source and drain))) and(thin adj film adj transistor\$2 tft lcd soi display\$2 silicon adj insulator\$2))	EPO; JPO; DERWENT	2003/12/30 20:56
8	2	((molybdenum MO chrom\$4 cr tantalum ta tungsten titanium)near21(aluminum))and ((( ((multi\$1layer\$3 multiple\$1layer\$3 double\$1layer\$3 two\$1layer\$3 triple\$1layer\$2)near7(source and drain))) and(thin adj film adj transistor\$2 tft lcd soi display\$2 silicon adj insulator\$2)))	EPO; JPO; DERWENT	2003/12/30 21:00
9	169	(stccp step\$2 deep)and (((molybdenum MO chrom\$4 cr tantalum ta tungsten titanium)near21(aluminum))and ((( contact via through) adj3( hole\$2)) and (( ((multi\$1layer\$3 multiple\$1layer\$3 double\$1layer\$3 two\$1layer\$3 triple\$1layer\$2)near7(source and drain))) and(thin adj film adj transistor\$2 tft lcd soi display\$2 silicon adj insulator\$2))))	USPAT; US-PGPUB	2003/12/30 21:08
10	8	( deep)and (((molybdenum MO chrom\$4 cr tantalum ta tungsten titanium)near21(aluminum))and ((( contact via through) adj3( hole\$2)) and (( ((multi\$1layer\$3 multiple\$1layer\$3 double\$1layer\$3 two\$1layer\$3 triple\$1layer\$2)near7(source and drain))) and(thin adj film adj transistor\$2 tft lcd soi display\$2 silicon adj insulator\$2))))	USPAT; US-PGPUB	2003/12/30 21:01
11	22	(( contact via through) adj3( hole\$2))near31(stEEP step\$2 deep)) and (( ((multi\$1layer\$3 multiple\$1layer\$3 double\$1layer\$3 two\$1layer\$3 triple\$1layer\$2)near7(source and drain))) and(thin adj film adj transistor\$2 tft lcd soi display\$2 silicon adj insulator\$2))	USPAT; US-PGPUB	2003/12/30 21:02
12	9	(steEP)and (((molybdenum MO chrom\$4 cr tantalum ta tungsten titanium)near21(aluminum))and ((( contact via through) adj3( hole\$2)) and (( ((multi\$1layer\$3 multiple\$1layer\$3 double\$1layer\$3 two\$1layer\$3 triple\$1layer\$2)near7(source and drain))) and(thin adj film adj transistor\$2 tft lcd soi display\$2 silicon adj insulator\$2))))	USPAT; US-PGPUB	2003/12/30 21:09